

Electronic Supplementary Information

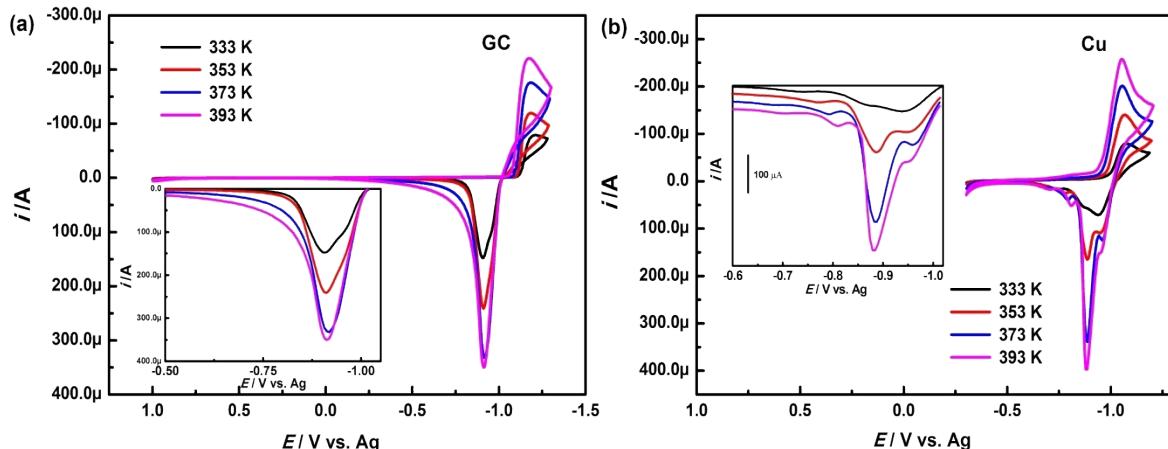


Fig. S1 Comparison of CVs for zinc deposition and stripping recorded at (a) glassy carbon (GC) and (b) copper electrodes from 0.1 M ZnO/ChCl–urea eutectic melt at various temperatures with a scan rate of 0.02 V s⁻¹. Inset shows an enlarge vision of the corresponding anodic stripping region.

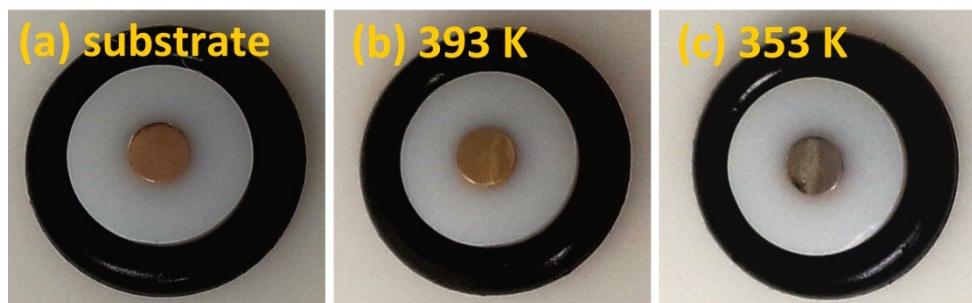


Fig. S2 Optical photographs. Front views of the top surface of copper electrodes (Φ 2 mm) before (a) and after a single CV measurement at (b) 393 K and (c) 353 K.

Table S1 Effect of temperature on the charge passed during the cathodic deposition process Q_c , the anodic stripping process, Q_a , and $|Q_a/Q_c|$ recorded at GC and Cu electrodes, respectively, taken from CVs in Fig. S1.

Temperature/K	$Q_c/10^3 C^{Cu}$	$Q_a/10^3 C^{Cu}$	$Q_c/10^3 C^{GC}$	$Q_a/10^3 C^{GC}$	$ Q_a/Q_c ^{Cu}$	$ Q_a/Q_c ^{GC}$
333	-1.022	0.742	-0.813	0.752	72.60	92.50
353	-1.720	1.210	-1.587	1.440	70.35	90.74
373	-2.543	1.663	-2.558	2.229	65.40	87.14
393	-3.373	1.918	-3.139	2.567	56.86	81.78

Table S2 Mean \pm one standard deviation (SD) values of roughness and peak-to-valley height of the samples prepared at different conditions using atomic force microscopy (AFM)

Current density /mA cm ⁻²	Deposition temperature /K	Dealloying temperature /K	Charge density /C cm ⁻²	Mean roughness /nm	Mean peak-to-valley height /nm
1.0	393	393	1.25	50.2 \pm 4.5	237 \pm 22
1.0	393	373	1.25	48.3 \pm 2.7	226 \pm 21
1.0	393	353	1.25	45.2 \pm 2.1	221 \pm 18
0.75	393	393	1.25	50.7 \pm 4.1	326 \pm 23
0.50	393	393	1.25	53.2 \pm 4.8	393 \pm 26
1.0	393	393	0.625	36.7 \pm 3.1	203 \pm 19
1.0	393	393	2.50	80.6 \pm 6.5	405 \pm 28
1.0	373	393	1.25	48.1 \pm 2.0	201 \pm 12
1.0	353	393	1.25	25.2 \pm 2.2	158 \pm 10